



SEM-3062

Scanning Electron Microscope ECO



EPCC / PRODUCTS / APPLICATION / SOFTWARE / ACCESSORIES / CONSUMABLES / SERVICES

Analytical Technologies Limited

An ISO 9001 Certified Company

www.analyticalgroup.net



- The SEM are magnification continuously adjustable, widly working distance, extended depth of field and easy to observe rough specimen, with these features, combine with STM/AFM to help with the location issue in STM/AFM.
- SEM in charge of area selection, and then move the probe to the corresponding area for detailed imaging. The system can realize direct specimen observation from marcoscopical to microcosmic, milimeter to nanometer and roughen surface to smooth surface.

>> Specifications:

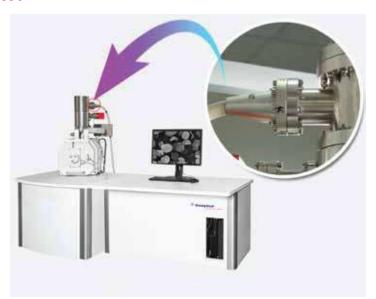
Resolution:		1nm@30KV(SE);3nm@1KV(SE); 2.5nm@30KV(BSE)
Magnification :		15x~800000x
Electron Gun :		Emission Electron Gun
Electron Beam Current :		10pA~0.3μA
Accelerating Voatage :		0~30KV
Lens System :		Three-level Electromagnetic Lens (Tapered Lens)
Objective Aperture :		Molybdenum Aperture Adjustable Outside Vacuum System
Vacuum System :		Ion Pump, Turbo Molecular Pump、Rotation Pump, Getter Pum
Detector:		High Vacuum Secondary Electron Detector (With Detector Protection)
		Semiconductor Four Segmentation Back Scattering Detector
Specimen Stage :		Five Axes Eucentric Motorized Stage
Travel Range :	Х	0~150mm
	Υ	0~150mm
	Z	0~60mm
	R	360°
	Т	-5°~75°
Max Specimen Diameter :		320mm
Modification :		EBL;STM;AFM;Heating Stage;Cryo Stage;Tensile Stage;Micro-nano
		Manipulator;SEM+Coating Machine;SEM+Laser Etc.
Accessories :		CCD,X-Ray Detector(EDS),EBSD,CL,WDS,Coating Machine Etc.

SOFTWARE INTRODUCTION:

- SEM 3062 support five windows synchronous, four chanel (SE+BSE) with CCD window.
- Auto Function:focus, bright/contrast, astigmation auto remove, electron beam centering, auto high voltage, auto filament, electron gun auto correction, fauclty detection, optional 3D scanning etc.
- Image Resolution: 16384*16384 pixels.
- Image Format : BMP, GIF, TIF, JPG, MNG, ICO, CUR, TGA, PCX, JP2, JPC, PGX, RAS, PNM, SKA, SEM.

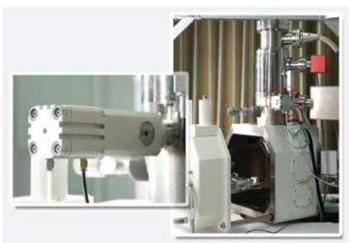


PRODUCT DISPLAY:



Emission Electron Gun





The Isolating Valve Ensures That The Upper Vacuum Is Not Affected When The Sample Room Is Opened

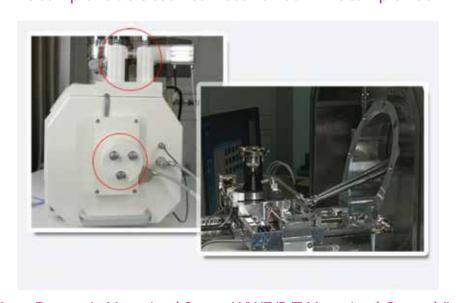




The Aperture Plate Has Three Nano-sized Holes Through Which Light Passes



The Sample To Be Observed Need To Put In The sample Room

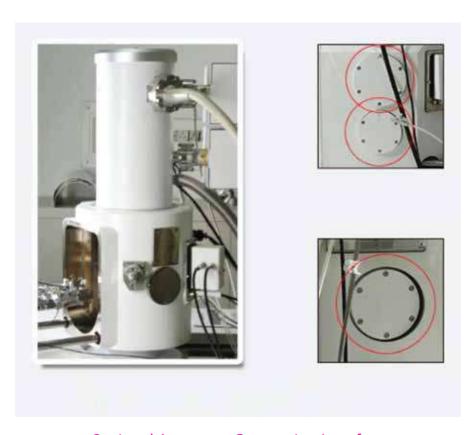


Five Axes Eucentric Motorized Stage, X/Y/Z/R/T Motorized Control (Large)



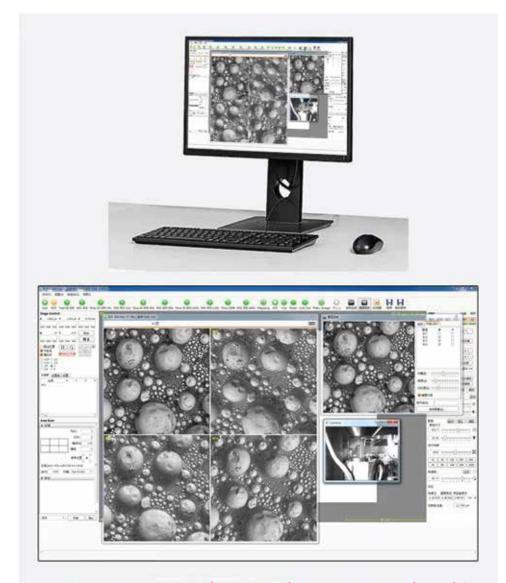


High Vacuum Secondary Electron Detector



Optional Accessory Connection Interface





SEM-3062 Support Five Windows Synchronous, Four Chanel (SE+BSE) with CCD Window;Image Resolution: 16384*16384 Pixels

DESCRIPTIONAL ACCESSORIES:



♦ BSE Detector

Semiconductor Four Segment Back Scattering Detector; Available In Ingredients A+B, Morophology Into A-B: Available sample Observe Without Sputtering Gold; Available In Observe Impurity And Distribution From Grayscale Map Directly.



◆ EDS (X Ray Detector)

Silicon Nitride (Si3N4) Window To Optimize Low Energy X-ray Transmission For Light Element Analysis; Excellent Resolution And Their Advanced Low-noise Electronics Provide Outstanding Throughput Performance; The Small Footprint Offers Flexibility To Ensure Ideal Geometry And Aata Collection Conditions; The Detectors Contain A 30mm² Chip.



♦ EBSD (Electron Beam Backscattered Diffraction)

user could analysis crystal orientation, crystal phase and micro texture of materials and related materials performance, etc.

automatic optimization of EBSD camera settings during the data collection, do interactive real-time analysis to obtain maximum information

all the data were branded with time tag, which can be viewed at any time

high resolution 1392 x 1040 x 12

Scanning and index speed: 198 points / sec, with Ni as the standard, under the condition of 2~5nA, it can ensure the index rate ≥99%;

works well under the condition of low beam current and low voltage of 5kV at 100pA

orientation measuring accuracy: Better than 0.1 degrees Using triplex index system: no need rely on single band definition, easy indexing of poor pattern quality dedicated database: EBSD special database obtained by electron diffraction: >400 phase structure Index ability: it can automatically index all crystal materials of 7 crystal systems.

The advanced options include calculating elastic stiffness (Elastic Stiffness), Taylor (Taylor) factor, Schmidt (Schmid) factor and so on.



◆ Coating Machine

Glass Protecting Shell: 250mm: 340mm High;

Glass Processing Chamber: 88mm; 140mm High, 88mm; 57mm High;

Specimen Stage Size: 40mm (max);

Vacuum System:molecula Pump And Mechanical Pump;

Vacuum Detection: Pirani Gage; Vacuum:better Than 2 X 10-3 Pa;

Vacuum Protection: 20 Pa With Microscale Inflation Valve; Specimen Movement: Plane Rotation tilt Precession.







◆ Ion Sputtering Coater

Glass Processing Chamber: 100mm; 130mm High; Specimen Stage Size: 40mm(Hold 6 Specimen Cups);

Golden Target Size: 58mm*0.12mm(thickness);

Vacuum Detection: Pirani Gage;

Vacuum Protection:20 Pa With Microscale Inflation Valve; Medium Gas:argon Or Air With Argon Gas Special Air Inlet

And Gas Regulating In Microscale.

♦ Argon Ion Sputtering Coater

The Sample Was Plated With Carbon And Gold Under High Vacuum,

Rotatable Sample Table, Uniform Coating, Particle Size About 3-5nm:

No Selection Of Target Material, No Damage To Samples; The Functions Of Ion Cleaning And Ion Thinning Can Be Realized.





◆ Critical Point Dryer

Inner Diameter: 82mm, Inner Length: 82mm

Pressure Range:0-2000psi;

Temperature Range:0°-50° C (32°-122° F)

◆ Electron Beam Lithography

Based On Scanning Electron Microscope, A Novel
Nano-exposure System Was Developed
The Mod ificaton Has Kept All The Sem Functions For
Making Nanoscale Line Width Image;
The Modificated Ebi System Widly Applied Into
Microelectronic Devices, Optoelectronic Devices, Quantun
Devices, Microelectronics System R&d.





◆ Uninterrupted Power Supply

Input Voltage:380v/220v

Input Voltage Range:120v 275v(176v — 275v Fully

Loaded Operation)

Output Voltage/output Distortion: 220v/230v/240v ± 1%,thdu <2%

Output Frequency Range:40hz~70hz,50hz/60hz

(self-adaption)

Efficiency: >93.5%(on-line Mode);98%(eco Mode)

Overload Capacity: 105%~125%:10 Mins 125%~150%:30s >150%:500ms

Parallel Operation: max Three I nstruments(optional)

Battery Voltage:192v(216v;240v Option) Charge Current:4a,8a Upgradable

Display: Led Screen

Communication Interface:rs232 Standard, Usd Extendable

Software:winpower

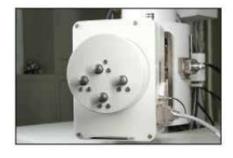
Operating Environment: 0 ~ 40°C

Noise: ≤50db

Size: 212 X 420 X 500 (mm)

Weight:16.9kg





♦ Five Axes Eucentric Motorized Stage, XIY/ZIT/R Motorized Control (Small)

X: 0~80mrn

Y: 0~50mm

Z: 0~30mm

R: 3600

T: -5°~70°

◆ Five Axes Stage, X/Y Motorized Control (Large)

X: 0~80mm

Y: 0~60mm

Z: 0~50mm

R: 3600

T: -5°~90°





♦ Five Axes Stage, XIY Motorized Control (Small)

X: 0~50mm

Y: 0~50mm

Z: 0~25mm

R: 3600

T: -5°~90°



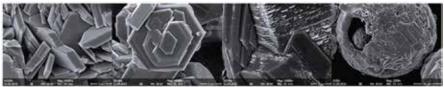


♦ Motorize Control Panel

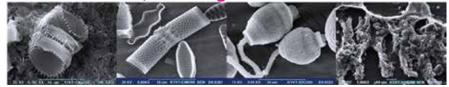
Motorize Control Panel, Intergrated Computer Mouse To Control Magnification, Brightness, Contrast, Focus, Working Stage Moving Easily.

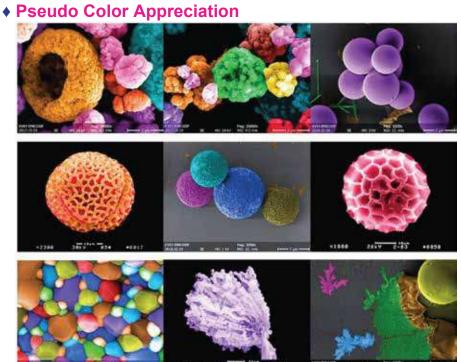
>> APPLICATION AND CASE:

◆ Ceramic material



Flora And Fauna, Microorganism







HPLC Servicing, Validation, Trainings and Preventive Maintenance:

HPLC Servicing: HPLC Servicing: We have team of service engineers who can attend to any make of HPLC promptly @the most

affordable cost.

Trainings :We also take up preventive Maintenace to reduce downtime of HPLC's Trainings.

AMC's/CMC :AMC's/CMC :We offer user training both in-House and at customer sites on HPLC principles, operations, trouble-

shooting.

Validations :Validations :We have protocols for carrying out periodic Validations as per GLP/GMP/USFDA norms.

Instruments: We offer instruments/Renting Services Modules like pumps, detector etc. on Rent.





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Our Products & Technologies



UV/VIS Spectro 2080+ Double Beam



Infra FTIR



Optima Gas Chromatograph 3007



Optima Gas Chromatograph 2979 Plus



Flash Chromatograph



Atomic Absorption Spectrophotometer



Liquid Partical Counter



Optical Emission Spectrophotometer



DSC/TGA



Semi Auto Bio Chemistry Analyzer



HEMA 2062 Hematology Analyzer



Micro Plate Reader/Washer



URINOVA 2800 Urine Analyzer



Total Organic Carbon 3800



Fully Automated CLIA



NOVA-2100 Chemistry Analyzer



PCR/Gradient PCR/ RTPCR



TOC Analyzer



Laser Particle Size Analyzer



Ion Chromatograph



Water purification system

Regulatory compliances



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Analytical Foundation is a nonprofit organization (NGO) found for the purpose of:



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- 2. Improving quality of life by offering YOGA Training courses, Work shops/Seminars etc.
- 3. ANALYTICAL FOUNDATION aims to DETOXIFY human minds, souls and body by means of yoga, Meditation, Ayurveda, Health Care, Awards, Media, Events, Camps etc.

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